



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the Application of: **Manabu NAKAMURA et al.**

Group Art Unit: **2891**

Application Number: **10/659,748**

Examiner: **Bradley Smith**

Filed: **September 11, 2003**

Confirmation Number: **3468**

For: **METHOD OF MANUFACTURING SEMICONDUCTOR DEVICE  
HAVING GATE OR TUNNEL INSULATION FILM (AS AMENDED)**

Attorney Docket Number: **031140**

Customer Number: **38834**

**INFORMATION DISCLOSURE STATEMENT**  
**UNDER 37 C.F.R. §1.97(c)(1)/(e)(1)**

Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

February 11, 2008

Sir:

Applicants direct the attention of the Patent and Trademark Office to the documents listed on the attached Form PTO/SB/08. A copy of each non - U.S. document is attached.

This Information Disclosure Statement (IDS) is being submitted after issuance of a first official action on the merits and expiration of the three month period following the filing date or the entry of the national stage for the above-captioned application, but prior to issuance of either a final official action or a Notice of Allowance.

The undersigned hereby certifies that each item of information contained in the IDS was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of the IDS. A copy of the foreign communication citing the documents is attached.

Information Disclosure Statement under 1.97(c)(1)  
Attorney Docket No. 031140  
Application No. 10/659,748

If there are any fees due in connection with the filing of this paper, please charge Deposit  
Account No. 50-2866.

Respectfully submitted,  
**WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP**



Kenneth H. Salen  
Attorney for Applicants  
Registration No. 43,077  
Telephone: (202) 822-1100  
Facsimile: (202) 822-1111

KHS/rf

Enclosures: PTO/SB/08  
3 Documents